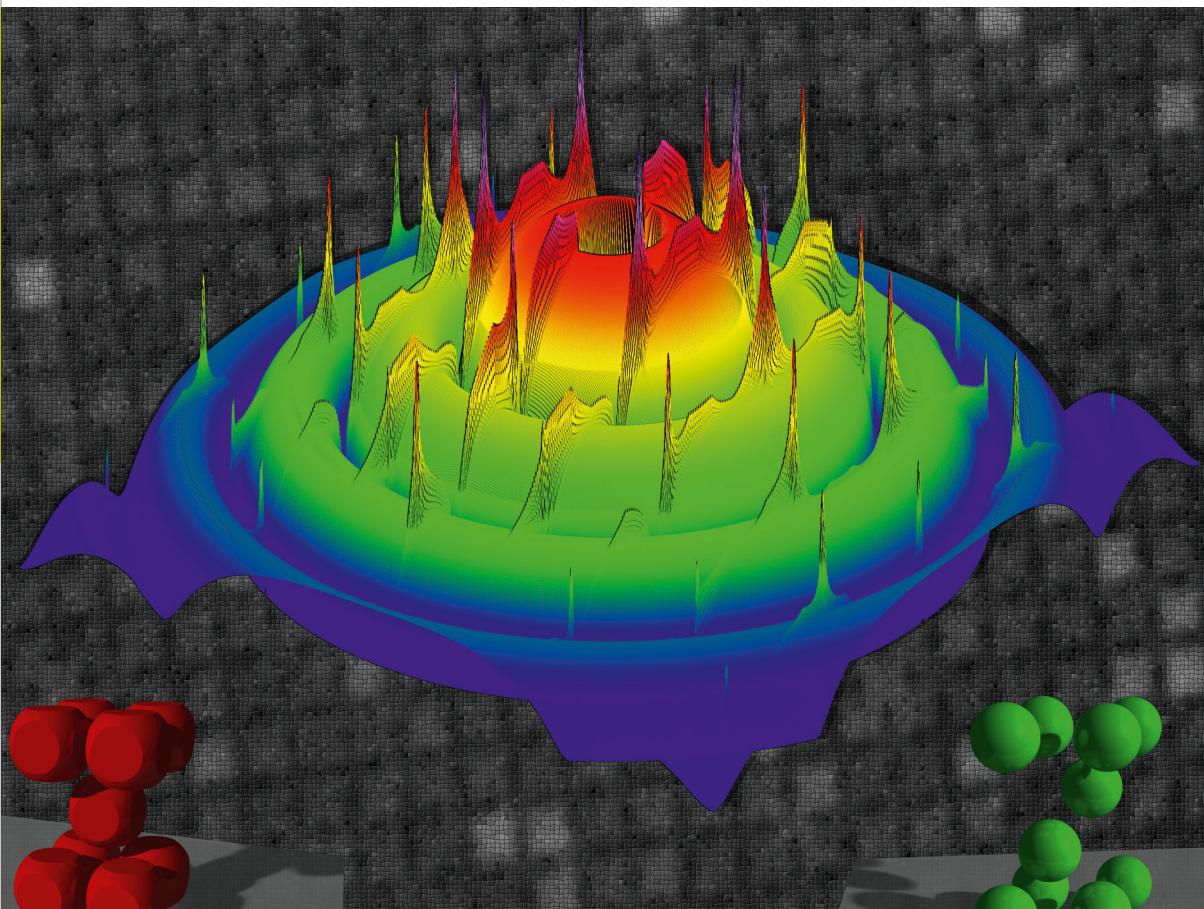


Long range order in 3D nanoparticle assemblies

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Scattering Methods (PGI-4 / JCNS-2)

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Schriften des Forschungszentrums Jülich
Reihe Schlüsseltechnologien / Key Technologies

Band / Volume 111

ISSN 1866-1807

ISBN 978-3-95806-087-6

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Schlüsseltechnologien /
Key Technologies
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ISBN 978-3-95806-087-6

